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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/773,658	02/09/2004	Yoichi Tamaki	XA-10036	7635
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1751 PINNACI			PHAM, LONG	
SUITE 500 MCLEAN, VA 22102-3833			ART UNIT	PAPER NUMBER
			2814	
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			09/13/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)
	10/773,658	TAMAKI ET AL.
Office Action Summary	Examiner	Art Unit
	Long Pham	2814
The MAILING DATE of this communication ap Period for Reply	ppears on the cover sheet with the	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING I - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the mailine earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATIO .136(a). In no event, however, may a reply be tind d will apply and will expire SIX (6) MONTHS from te, cause the application to become ABANDONE	N. mely filed the mailing date of this communication. ED (35 U.S.C. § 133).
Status		
Responsive to communication(s) filed on 17. This action is FINAL . 2b) ☐ This action is FINAL . Since this application is in condition for allowed closed in accordance with the practice under	is action is non-final. ance except for formal matters, pr	
Disposition of Claims		
4) Claim(s) 1-18 is/are pending in the application 4a) Of the above claim(s) is/are withdra 5) Claim(s) is/are allowed. 6) Claim(s) 1-18 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/	awn from consideration.	
9) The specification is objected to by the Examin	ier.	
10) The drawing(s) filed on is/are: a) ac Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the E	cepted or b) objected to by the edrawing(s) be held in abeyance. Section is required if the drawing(s) is ob	e 37 CFR 1.85(a). ejected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for foreig a) All b) Some * c) None of: 1. Certified copies of the priority documer 2. Certified copies of the priority documer 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	nts have been received. nts have been received in Applicat ority documents have been receiv au (PCT Rule 17.2(a)).	ion No ed in this National Stage
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal I 6) Other:	ate

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DETAILED ACTION

New grounds of rejection

Claim Rejections - 35 USC § 103

The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Claims 1-18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takashi et al. (Japan 2002-057219) in combination with Kinoshita (US pat 6,300,669) and Moyer (US patent 5,374,844).

With respect to claims 1, 6, 10, Takashi et al. a semiconductor device comprising (see figs. 1-6 and English abstract):

- a) a semiconductor layer 3 that is provided over a layer (a p-n junction at the interface between 2 and 3) of electrically insulating material (since the p-n junction electrically insulates the bipolar transistors);
- b) a plurality of first bipolar transistors 18,19 are provided on the semiconductor layer; and
- c) an first isolation 4-1, 4-4 is provided over a main surface of the semiconductor layer to reach the layer of electrically insulating material, and provided such that the isolation surrounds a group of or the whole of the plurality of bipolar transistors, such that the surrounded transistors would inherently operate substantially uniformly as constituent elements of a unit transistor.

Takashi et al. fail to teach that the collectors, emitters, and bases of the bipolar transistors are respectively connected in parallel with each other.

Kinoshita teaches collectors, emitters, and bases of a plurality of bipolar transistors are respectively connected in parallel with each other to achieve low-noise, high-power gain high frequency amplifier. See claim 1 and abstract.

It would have been obvious to one of <u>ordinary skill</u> in the art of making semiconductor devices to incorporate the teaching of Kinoshita into the device of Takashi et al. to attain the above benefit.

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With respect to claims 2, 3, 7, 11, and 12, Takashi et al. further fail to teach each of emitter of the plurality of bipolar transistors is connected to a resistor made of polysilicon.

Moyer teaches connecting a polysilicon resistor to an emitter of a bipolar transistor to prevent thermal runaway. See col. 1, lines 35-40.

It would have been obvious to one of <u>ordinary skill</u> in the art of making semiconductor devices to incorporate the teaching of Moyer into the device of Takashi et al. to attain the above benefit.

With respect to claims 4, 5, 8, 9, 13, 14, and 15, Takashi et al. implicitly teach collector and base contact holes but fail to teach the range for the distance between contact holes for the base and collector of plurality of first and second bipolar transistors.

However, it would have been obvious to one of <u>ordinary skill</u> in the art of making semiconductor devices to determine the workable or optimal value or range for the distance between contact holes for the base and collector through routine experimentation and optimization to obtain optimal or desired device performance because in the absence of unexpected results and it has been held that it is not inventive to discover the optimum or workable ranges of a result-effective variable within given prior art conditions by routine experimentation. See MPEP 2144.05.

Further with respect to claim 6, since Takashi et al. in combination with Moyer teach emitters of the bipolar transistors are connected and the emitters are connected to the resistors, the resistors are connected to each other.

Further with respect to claim 10, Takashi et al. further teach a plurality of second bipolar transistors 20, 21 are provided on the semiconductor layer and an second isolation 4-1, 4-4 is provided over a main surface of the semiconductor layer to reach the insulation layer, and provided such that the isolation surrounds a group of or the whole of the plurality of bipolar transistors, such that the surrounded transistors would inherently operate substantially uniformly as constituent elements of a unit transistor.

Further with respect to claim 10, Takashi et al. in combination with Kinoshita and Moyer further teach that the collectors, emitters, and bases of the bipolar transistors or

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first and second bipolar transistors are respectively connected in parallel with each other.

With respect to claims 16 and 17, Takashi et al. in combination with Kinoshita and Moyer fail to teach that the optimum current of the first bipolar transistor 1.5 times larger than the second bipolar transistor.

With respect to claim 18, Takashi et al. in combination with Kinoshita and Moyer fail to teach that the relative heat radiation and operation speed of the first bipolar transistor and the second bipolar transistor.

However, it would have been obvious to one of <u>ordinary skill</u> in the art of making semiconductor devices to determine the workable or optimal value or range for the relative heat radiation and operation speed of the first bipolar transistor and the second bipolar transistor through routine experimentation and optimization to obtain optimal or desired device performance because in the absence of unexpected results and it has been held that it is not inventive to discover the optimum or workable ranges of a result-effective variable within given prior art conditions by routine experimentation. See MPEP 2144.05.

Response to Arguments

Applicant's arguments with respect to claims 1-18 have been considered but are moot in view of the new ground(s) of rejection.

In response to the applicant's arguments in the paragraphs on pages 11 and 12 of the amendment dated 07/17/07, it is submitted that the layer or interface between regions 2 and 3 constitutes an electrically insulating material.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Long Pham whose telephone number is 571-272-1714. The examiner can normally be reached on Mon-Frid, 10am to 5pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on 571-272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Long Pham/
Primary Examiner, Art Unit 2814

/L. P./